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		OTHER DOC	UMENTS	(Including Author,	Title, Date, Pertiner	nt Pages, etc.	)		
	C1	Aluminium oxide, Wiki June 12, 2007, 5 pgs.	pedia, the fr	ee encyclopedia	, downloaded from	http://en.wi	kipedia.org	/wiki/Al	lumina
	C2	Ceramic, Wikipedia, the free encyclopedia, downloaded from <a href="http://en.wikipedia.org/wiki/Ceramic">http://en.wikipedia.org/wiki/Ceramic</a> . June 12, 2007, 8 pgs.  **Ceramics-a.k.a. "burnt stuff"- contain at least 1 metal oxide", CCMR-Ask A Scientist, downloaded from <a href="http://www.ccmr.cornell.edu/education/ask/index.html?quid=1088">http://www.ccmr.cornell.edu/education/ask/index.html?quid=1088</a> , June 12, 2007, 2 pgs.							
	СЗ								
	C4								
	C5	Chen et al., "Al <sub>2</sub> O <sub>3</sub> - TiO <sub>2</sub> composite oxide films on etched aluminum foil by gydrolysis precipitation and anodizing", J. Mater. Sci. 41, pp. 569-571 (2006).							
	C6	Ciridon et al., "Plasma Deposition", Biomaterials Tutorial, Univ. of Washington Engineerred Biomaterials, 2004, 3 pgs.							
	C7	Holcombe Jr. et al., "Oxygen sensitive, refractory oxide composition", downloaded from http://www.patentdigi.com/liquid_crystal/oxygen_sensitive_refractory_oxide_composition. June 12, 2007, 7 pgs.							
	C8	Kern et al., "Electrolytic Deposition of Valve Metal Oxide Thin Films as Interference Coatings on Biomedical Implants", EU Cells and Materials vol. 10, Suppl. 1, 2005, pg. 25.							
	C9	"Plasma Processing and Low Energy Plasma Science" The National Academies Press, downloaded from <a href="http://books.nap.edu/openbook.php?record_id">http://books.nap.edu/openbook.php?record_id</a> , June 12, 2007, 5 pgs.							
	C10	Zhitomirsky, "Ceramic Films Using Cathodic Electrodeposition", downloaded from http://www.tms.org/pubs/journals/JOM/0001/Zhitomirsky/, June 12, 2007, 11 pgs.							
	C11 Wood et al., "Implantation and deposition of adherent metal-oxide ceramic", IEEE Xplore, downloaded from http://ieeexplore.ieee.org/xpl/freeabs_all.jsp?arnumber=533482, June 12, 2007, 1 pg.								
EXAMINER				DATE CON	SIDERED				
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